International Standard



431

INTERNATIONAL ORGANIZATION FOR STANDARDIZATION MEXALYHAPODHAR OPFAHUSALUN TO CTAHDAPTUSALUNOORGANISATION INTERNATIONALE DE NORMALISATION

Copper refinery shapes

Formes brutes d'affinage du cuivre

Second edition - 1981-12-15

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<u>ISO 431:1981</u> https://standards.iteh.ai/catalog/standards/sist/3ad093d8-0ae3-4708-afae-66019674523a/iso-431-1981

Ref. No. ISO 431-1981 (E)

Descriptors : copper, refining, shape, designations, chemical composition, electrical properties, impurities, mass, tolerances, dimensions, chemical analysis, physical tests, defects.

Foreword

ISO (the International Organization for Standardization) is a worldwide federation of national standards institutes (ISO member bodies). The work of developing International Standards is carried out through ISO technical committees. Every member body interested in a subject for which a technical committee has been set up has the right to be represented on that committee. International organizations, governmental and non-governmental, in liaison with ISO, also take part in the work.

Draft International Standards adopted by the technical committees are circulated to the member bodies for approval before their acceptance as International Standards by the ISO Council.

International Standard ISO 431 was developed by Technical Committee ISO/TC 26, IEW Copper and copper alloys, and was circulated by the member bodies in November 1979. stanuar U.S.11

It has been approved by the member bodies of the following countries : ISO 431:1981

Australia	https://standards.iteh	ai/catalog/standards/sist/3ad093d8-0ae3-4708-afae-
Belgium	Hungary	6601967 \$523 7/iso-431-1981
Bulgaria	India	Sweden
Canada	Korea, Rep. of	Switzerland
China	Mexico	Turkey
Czechoslovakia	Netherlands	USA
Egypt, Arab Rep. of	Poland	USSR
Finland	Portugal	Yugoslavia
France	Romania	

The member bodies of the following countries expressed disapproval of the document on technical grounds :

Chile United Kingdom

This second edition cancels and replaces the first edition (i.e. ISO 431-1972), ISO Recommendations R 1428, R 1429 and R 1430 and International Standard ISO 2311.

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Copper refinery shapes

Scope and field of application 1

This International Standard specifies the requirements of refined copper listed in table 1, in the form of refinery shapes (unwrought products). The refinery shapes included are cathodes, horizontally, vertically and continuously cast wire bars, cakes, billets and ingots.

Table 1		Designation	and	terms	of	refined	copper
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Term

ISO 1190/1, Copper and copper alloys - Code of designation - Part 1 : Designation of materials.³⁾

ISO 1553, Unalloyed copper containing not less than 99,90 % of copper - Determination of copper content - Electrolytic method.

ISO 1554, Wrought and cast copper alloys - Determination of copper content - Electrolytic method.

ISO/R 1811, Chemical analysis of copper and copper alloys ---Sampling of copper refinery shapes.⁴⁾

Cu-CATH	Cathode copper	ISO 2626, Copper — Hydrogen embrittlement test.					
Cu-ETP	Electrolytically refined tough pitch copper	ISO 4746, Oxygen free copper — Scale adhesion test.					
Cu-FRHC	Fire-refined high-conductivity copper	IFC Publication 28 International standard of resistance for					
Cu-CRTP	Chemically refined tough-pitch copper	s. icoper. ai)					
Cu-FRTP	Fire-refined tough-pitch copper	IEC Publication 468, Method of measurement for resistivity of					
Cu-HCP	High-conductivity phosphorus-containing ISO 43	1:198 metallic materials.					
	copper https://standards.iteh.ai/catalog/stand	ards/sist/3ad093d8-0ae3-4708-afae-					
Cu-PHC	High-conductivity phosphorus-containing/74523 copper	a ^{/iso-4} .3 ¹⁻¹ Definitions					
Cu-PHCE	High-conductivity phosphorus-containing copper (electronic grade)	For the purpose of this International Standard, the definitions for refined copper in ISO/TR 197/1 and for refinery shapes in					
Cu-DLP	Phosphorus-deoxidized copper — Low residual phosphorus	ISO/TR 197/2, as well as the principles for the designation of copper in ISO 1190/1, apply.					
Cu-DHP	Phosphorus-deoxidized copper — High residual phosphorus	4 Requirements					
Cu-OF	Oxygen-free electrolytically refined copper						
Cu-OFE	Oxygen-free electrolytically refined copper (electronic grade)	4.1 Composition and properties					
Cu-Ag (OF)	Oxygen-free copper-silver	quirements for composition and physical properties specified in					
Cu-Ag	Tough-pitch copper-silver	tables 2 and 3 as appropriate.					
Cu-Ag (P)	Phosphorus-deoxidized copper-silver	4.2 Refinery shapes					

table 2.

2 References

Designation

ISO 197, Copper and copper alloys – Terms and definitions.

- Part 1 : Materials. 1)
- Part 2 : Unwrought products.²⁾

4) Under revision.

The shapes in which each grade is available are shown in

Wire bars, cakes and billets are intended for fabricating into wrought products; ingots are intended for alloying in wrought and cast copper alloys.

¹⁾ At present at the stage of draft. (Revision of ISO/TR 197/1.)

At present at the stage of draft. (Revision of ISO/TR 197/2.) 2)

³⁾ At present at the stage of draft. (Revision of ISO/R 1190/1.)

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	Chemical	l composition		Refine	iry shap	es			Electrical proper	ties			Meth	ods of te	st
	Conner nhis	Other		ļ		•	ر q	Mandatory value	Equivaleı guidar	nt values 1 nce only ⁷⁾	or	ļ	ţŷ	test r	Hydrogen
nesignation	silver	elements	leo 16d	eno: 16d			ed 1 ed 1	Mass	Volume	Condu	ctivity	soin sis	ivita	e Iois	اس۔ brittlement
	% min.	%	Verti wire	Horiz Wire	еяеС	təlli8	togni Iogni	resistivity Ωg/m ² max.	resistivity ^{or} Ωmm ² /m max.	MS/m min.	% IACS min.	nəd) (lens	Resis test	edhe Scale	test
Cu-CATH	06'66	Teh ST		Cath.	odes on	DR	FV1	0,153,28	0,017 24	58,00	100,0	×	×		
Cu-ETP	06'66		×	×	×	×	×	0,153 28 ⁴⁾	0,017 24 ⁴⁾	58,00 ⁴⁾	100,0 ⁴⁾	×	×		
		(St	and	ard	S.ite	h.a		0, 155 96 ⁵⁾	0,017 545)	57,00 ⁵⁾	98,35)				
Cu-FRHC	06'66		×	×	×	×	×	0,153 284)	0,017 244)	58,004)	100,04)	×	×		
				SO 431	1981			0,155 96 ⁵⁾	0,017 545)	57,00 ⁵⁾	98,3 ⁵⁾				
Cu-CRTP	99,90 http://dth	s://standards.iteh.a	u/catalog	y/standan	ds/sist/3	ad@93d	18-0ae2	3-40,053,284)-	0,017 244)	58,004)	100,04)	×	×		
	4		660196	74523a/	so-431-	1981		0,155 96 ⁵⁾	0,017 545)	57,00 ⁵⁾	98,3 ⁵⁾				
Cu-FRTP	99,85				×	×	×					×			
Cu-HCP	99' 9 5	P 0,001-0,005 ⁹⁾	×		×	×		0,156 14			98,16	×	×		Close bend
Cu-PHC	<u> 9</u> 9,95	P 0,003	×		×	×		0,153 28	0,017 24	58,00	100,0	×	×		Close bend
Cu-PHCE	66'66	2)	×		×	×		0,151 76	0,017 07	58,58	101,0	×	×		10 reverse
	(excl. Ag)														bends
Cu-DLP	06'66	P 0,005-0,012			×	×		6)				×	(9		Close bend
Cu-DHP	99,85	P 0,013-0,04			×	×						×			Close bend
Cu-OF	99,95		×		×	×		0,153 28	0,017 24	58,00	100,0	×	×		Close bend
Cu-OFE	99,99 (avrl Δα)	2)	×		×	×		0,151 76	0,017 07	58,58	101,0	×	×	×	10 reverse bends
	(B														
Cu-Ag (OF)	3 6' 3 2	3)	×		×	×		0,153 28	0,017 24	58,00	100,0	×	×		Close bend
Cu-Ag	06'66	3)	×	×	×	×		0,153 28	0,017 24	58,00	100,0	×	×		
Cu-Ag (P)	06'66	3)			×	×		0,155 96 ⁵⁾	0,017 54	57,00	98,3	×	×		Close bend

1) According to ISO 1190/1.

See table 3.
Specific ranges of silver content between 0,01 and 0,25 % by agreement between the interested parties.
When copper is for electrical purposes.
When copper is for non-electrical purposes.
May be agreed between the interested parties.
See annex A.
The precise value is found in IEC Publication 28.
When made from an oxygen-free base copper, the oxygen content of HCP copper shall be less than 0,00.

When made from an oxygen-free base copper, the oxygen content of HCP copper shall be less than 0,001 %.

		values as	a percentage by mass
	Copper Element	Cu₋OFE	Cu-PHCE
	Arsenic	1)	1)
	Antimony	1)	1)
	Bismuth	0,001 ¹⁾	0,001 ¹⁾
	Cadmium	0,000 1	0,000 1 ¹⁾
	Iron	2)	2)
	Lead	0,001	0,001
	Manganese	1) 2)	1) 2)
	Mercury	0,000 1	0,000 1
	Nickel	2)	2)
	Oxygen	0,001	0,003 ³⁾
iT	e Selenium AND	AR ^{0,000 3} PR	EV ^{0,003(3)} 0,001 ¹⁾
	Silver(standa	rds. ² teh.a	2) 0,001 8
	Tellurium	0,0011)	0,001 ¹⁾
https://s	Tin andards.iteh.ai/catalog/si Zinc 66019674	0 431:1981 andards/sist/3ad0930 523a/iso, 431-1981	1) 18-0ae3-4708-afae- 0,000 1

Table 3 – Maximum impurity limits

1) Total of these seven elements not to exceed 0,004 %.

2) Analysis required. No limit established.

3) Approximate values.



Figure - Shapes and sizes of horizontally cast wire bars

	Dimensions in milli	metres for	masses in	kilograms	s (pounds)		
Symbol	Tolerance	91 (200)	102 (225)	113 (250)	120 (265)	125 (275)	136 (300)
/ ₁	± 1 %	1 370	1 370	1 370	1 370	1 370	1 370
12	± 0 mm	150	150	150	150	150	150
h ₁	± 6 mm	90	100	100	110	110	120
h ₂	± 6 mm	25	25	25	25	25	25
<i>b</i> 1	± 6 mm	100	100	110	110	110	110
b2	± 6 mm	90	90	100	100	100	100
<i>R</i> ₁	± 6 mm	16	16	25	25	25	25
R ₂	± 6 mm	16	16	16	16	16	16
R ₃	± 6 mm	40	40	40	40	40	40
α	± 2°	10°	10°	10°	10°	10°	10°
β	± 2°	10°	10°	10°	10°	10°	10°
γ	± 1°	3°	3°	3 ⁰	3°	3°	3°

Table 4 - Masses and dimensions of horizontally cast wire bars (see the figure)

4.3 Dimensions, masses and tolerances

4.3.1 Cathodes

Whole cathodes or cathodes cut to size may be supplied as agreed between the interested parties.

4.3.2 Wire bars (horizontally cast)

Wire bars shall have masses, dimensions and tolerances as selected from table 4 and the figure.

4.3.3 Billets

Billets shall be ordered by diameter and length. For diameters of billets up to and including 200 mm, a variation of \pm 3 mm is permissible. If closer tolerances on diameters are required, they shall be agreed between the interested parties. For diameters of billets over 200 mm tolerances on diameter shall be as agreed between the interested parties. Billets may vary in length by \pm 2 % from the specified length unless otherwise agreed, and shall be straight within 4 mm per metre length. Unless otherwise specified, billets of phosphorus-deoxidized copper less than or equal to 100 mm in diameter may be supplied sheared at one end. The other end shall be flat.

4.4.1 Cathodes shall withstand ordinary handling without ex-

cessive breakage or excessive separation of nodules and shall

be reasonably free from all foreign material such as copper

4.4.2 Cakes, billets and wire bars shall be substantially free from shrink holes, cracks, cold sets, pits, sloppy edges, concave tops and other similar defects in set or casting. These requirements do not apply to ingots and ingot bars in which physical defects are of minor consequence.

5 Marking

All shapes intended for fabrication shall be permanently marked with the manufacturer's brand and furnace charge mark or production number. Ingots shall have a brand stamped or cast in, but need not have a furnace charge mark.

6 Lots

The manufacturers should endeavour to arrange lots so that, as far as possible, each lot contains pieces from one furnace charge or production lot only.

7 Chemical analysis

7.1 Sampling for chemical analysis

Billets over 100 mm in diameter shall be supplied with both ends flat. Billets shall not be cupped except by specific agree such procedures apply. ment at the time of purchase.

4.3.4 Other shapes

ble within the limits shown in table 5.

4.4 Physical condition

sulphate, dirt, grease and oil.

7.2 Methods of analysis ISO 431:1981

https://standards.itch.ai/catalog/standards/sisThe methods used for determining the copper content of cop-Other shapes not dealt with in 4.3.1 to 4.3.3 are static and con-a/iso-4 personf 99,90 % purity or greater shall be in accordance with tinuously vertically cast wire bars, vertically and horizontally cast cakes and ingots. Variation from ordered size is permissi-

> The copper content of Cu-OFE and Cu-PHCE shall be determined by subtracting the total of the concentrations of impurities determined from 100 %. The impurity total is defined as the sum of the seventeen elements in table 3. The analytical methods for determining the impurities in Cu-OFE and Cu-PHCE shall, in all cases of disagreement, be as agreed between the supplier, the purchaser and any mutually acceptable arbitrator.

Shape	Mass	Width and thickness	Other dimensions
Vertically continuously cast wire bars	± 5 %	± 3 mm	± 6 mm
Vertically static cast wire bars	± 5 %	± 6 mm	± 6 mm
Vertically and horizontally cast cakes	± 5 %	≤ 200 mm ± 6 mm > 200 mm ± 3 %	≤ 200 mm ± 6 mm > 200 mm ± 3 %
Ingots	+ 10 %		

Table 5 – Other shapes – Permissible variations from ordered size

8 Physical testing

8.1 Resistivity test

For electrolytic cathode copper, Cu-CATH, the resistivity shall be determined from a representative sample of each batch of less than 50 t or from each 50 t lot. Samples shall be melted under charcoal in a pure graphite crucible and then chill cast to a form suitable for working.

For shapes other than cathode copper, samples may be taken either while still molten or by cutting from representative portions of the cast shape.

The sample may be hot-worked initially, if required, provided that care is taken to avoid contamination or excessive oxidation. External oxide shall be removed and the sample then rolled or drawn to 2 mm diameter, degreased and annealed at 500 °C for a minimum time of 30 min in an inert atmosphere.

The resistivity test shall be made in accordance with IEC publication 468.

Notes on the relationship between mandatory mass resistivity and the corresponding volume resistivity and conductivity are given in the annex.

8.2 Embrittlement test

Test specimens prepared from representative samples shall normally be forged or hot-rolled and cold-drawn into wire or strip of approximately 2,0 mm in diameter or thickness.

As a routine test, samples cut from cast copper may be used and the results accepted if satisfactory. In the event of failure, further tests shall be carried out on wrought specimens.

The hydrogen embrittlement test shall be carried out in accordance with ISO 2626. The types of tests to be carried out are detailed in table 2.

After bending, the stressed surface of the bent portion shall be visually inspected. No significant cracks shall be apparent to the unaided eye, corrected to normal vision.

8.3 Scale adhesion test

Cu-OFE copper shall be tested in accordance with ISO 4746.

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Annex

Notes on resistivity and conductivity relationships

(This annex forms part of the Standard.)

A.1 Mass resistivity

This International Standard is intended to prescribe a minimum quality for the copper specified including, for several grades, their electric current carrying suitability.

Because measurement of cross-sectional areas to the requisite degree of accuracy is difficult, in practice nearly all assessments are made by measuring the resistance, mass, and length of a representative sample. From these values mass resistivity can be calculated directly and this gives a true measure of the quality of the copper for carrying electric current.

Mass resistivity has therefore been taken as the mandatory property in this International Standard.

A.2 Standard annealed coppes TANDARD

IEC Publication No. 28-1925, first published in 1914, uses volume resistivity and for nominal evidence from earlier years (see USA National Bureau of Standards Circular 31, 1956, superseded by USA National Bureau of Standards Handbook 100, 1966) to establish a fixed value for 1:1981 the resistance to flow of an electric current within an imaginary rds/sist/3ad/093d8-0ae3-4708-afae-

"standard" annealed copper. This is based on a volume resisation tivity of 1/58 or 0,017 241... Ω mm²/m* at 20 °C.

Also on this earlier evidence the standard annealed copper is allotted a density of 8,89 g/cm³ (8 890 kg/m³ in SI units).

A.3 Commercial annealed copper

In addition IEC publication 28 states that "the (electrical) conductivity of commercial annealed copper shall be expressed as a percentage at 20 $^{\circ}$ C, of that of standard annealed copper... to... 0,1 %... on the assumption (that) the density of commercial annealed copper is (also) 8,89 grams per cubic centimetre''.**

A.4 Nominal volume resistivity

In fact, the density of commercial copper varies with small changes in composition, particularly oxygen content (see ISO 197). Thus, a true volume resistivity can only be calculated from a measured mass resistivity if the true density of the particular sample is known or is measured to the requisite degree of accuracy, i.e. better than 0,1 %.

For general purposes, however, a nominal volume resistivity may be calculated using the density of 8 890 kg/m³, as referred to in clause A.2. This practice has been adopted in table 2 of this International Standard in presenting values for nominal volume resistivity and for nominal conductivity corresponding to the mandatory mass resistivity.

A.5₉₈₁Differences between measured and nominal values

If true volume resistivity or true conductivity is required from measured mass resistivity and therefore actual density is used in calculation, differences of up to 0,6 % (for example for oxygen-free coppers) may result between these values and the corresponding nominal values.

Conductivity calculated from the ratio of the mass resistivity of standard annealed copper (0,153 28...) to the observed mass resistivity may also exhibit similar disparities.

^{*} Microhm metre in SI units; the introduction of the International ohm in 1948 altered the volume resistivity of standard annealed copper by only 0,049 %.

^{**} No underlining is used in IEC Publication 28.